



Micropatterned high permeability films with narrow bandwidth resonance loss for the band stop filter

著者	IKEDA Shinji, NAGAE Tatsuya, SHIMADA Yutaka, KIM KI HYEON, YAMAGUCHI Masahiro
journal or	Journal of Applied Physics
publication title	
volume	99
number	8
page range	08P507
year	2006
URL	http://hdl.handle.net/10097/52016

doi: 10.1063/1.2171950

Micropatterned high permeability films with narrow bandwidth resonance loss for the band stop filter

Shinji Ikeda,^{a)} Tatsuya Nagae, Yutaka Shimada, Ki Hyeon Kim, and Masahiro Yamaguchi Department of Electrical and Communication Engineering, Graduate School of Engineering, Tohoku University, Sendai 980-8579, Japan

(Presented on 3 November 2005; published online 24 April 2006)

In this work the micropatterned CoNbZr films designed for the band stop filter are reported. It was already reported that a 400- μ m-wide coplanar line equipped with a 4-mm-wide CoNbZr film exhibits band stop characteristics, but practically the width of the film must be about the same size as the signal line. This limited width of the micropattern gives rise to dispersion of the shape anisotropy, resulting in degradation of band stop characteristics. Here we fabricated 150- μ m-wide patterned films with adjusted edge dimensions which widths have been enlarged from 20 to 40 μ m that were optimized on the permeability database. The resonance loss profile for the adjusted pattern is compared with that of a film without adjusted edges. The half width is appreciably decreased from 2.2 to 0.77 GHz. In conclusion an improvement of the resonance profile of micropatterned films was achieved by optimizing the edge dimensions. This will enable us to utilize magnetic films for more downsized signal lines. © 2006 American Institute of Physics. [DOI: 10.1063/1.2171950]

I. INTRODUCTION

Recently a band stop filter using ferromagnetic films has been investigated.¹ Their characteristics are improved by narrowing the resonance loss profile by applying a dc field. On the other hand, we have reported band stop characteristics using micropatterned ferromagnetic CoZrNb film.² The ferromagnetic resonance frequency is controlled by the pattern shape, therefore an external dc field is not required. The effective anisotropy field of micropatterned films depends on the shape anisotropy of each rectangular film and the magnetostatic interaction between neighboring films. The most of rectangular films have two neighboring films in both side, however, the rectangular film on the edge has a single neighbor. This structural difference causes dispersion of the anisotropy because of an increase of an anisotropy field on the edge. In the case of a band stop filter for narrow transmission lines, relatively large dispersion is unavoidable because the total number of rectangles is limited and the effect of an edge part is not negligible. We focus attention on the edge design of the film and optimize the edge part to reduce dispersion of the anisotropy appreciably.

II. DESIGN OF PATTERN SHAPE

The pattern shape is designed for $0.5-\mu$ m-thick CoZrNb film which saturation magnetization is 10 kG and intrinsic anisotropy field is 10 Oe. The permeability database³ for the micropatterned film and Osborn's equation⁴ for demagnetizing factor of ellipsoids are used for the estimation of effective permeability of micropatterned films and different pattern dimensions. We assumed that the edge film has half of the effective permeability of other films because the edge film has half of the magnetostatic interaction with neighboring films. A small dispersion of the shape anisotropy is re-

quired to get a sharp resonance loss peak, then the width of edge film is enlarged than others for same effective permeability. When 20/2.5 μ m (linewidth/slit width) and the total number of rectangle is limited to 5, the optimum width of edge film was estimated to be 40 μ m when the total width of whole of patterned film is 150 μ m.

III. SAMPLE PREPARATION

The samples were composed of sputtered 0.25- μ m-thick CoNbZr magnetic film, 10-nm-thick intermediate Nb, and 0.25- μ m-thick CoNbZr magnetic film on a glass substrate (see Fig. 1). The pattern was fabricated by ion milling method. The basic pattern dimension is 20/2.5 μ m (linewidth/slit width) and the widths of edge rectangles are 20, 30, 40, and 50 μ m. The samples were annealed twice in a dc field at 400 °C to reduce their anisotropy dispersion, once after deposition and once after patterning. Figure 2 shows photos of the samples, the sample shown in the left has 20 μ m width edges and the sample shown in the right has 40 μ m width edges.

IV. COMPLEX PERMEABILITY

The frequency characteristics of complex permeability was measured with a permeameter.⁵ In Fig. 3, the resonance



^{a)}Electronic mail: s-ikeda@ecei.tohoku.ac.jp

FIG. 1. Schematic view of micropatterned magnetic film.

99, 08P507-1

© 2006 American Institute of Physics

Downloaded 30 Aug 2011 to 130.34.134.250. Redistribution subject to AIP license or copyright; see http://jap.aip.org/about/rights_and_permissions



FIG. 2. Photograph of patterned films. The sample in the left has 20 μ m width and 2.5 μ m gap homogeneous edges, while the sample in the right has 40 μ m width edges.

loss profile for the adjusted edge pattern is compared with that of a film without adjusted edges. The half width is appreciably decreased from 2.2 to 0.77 GHz. Figure 4 shows the edge width dependence of resonance frequency and the half width of resonance loss. The resonance frequency is decreased by enlarging the edge width from 20 to 40 μ m, this means that the anisotropy of the edge elements is larger than these of the other parts in this dimension range.

V. CONCLUSION

An improvement of the resonance profile of micropatterned films was achieved by optimizing the edge dimensions. The half width of resonance loss is appreciably decreased from 2.2 to 0.77 GHz when the width of the edge is



FIG. 3. Measured frequency characteristics of normalized resonance loss.



FIG. 4. (Color online) The half width of resonance loss peak and resonance frequency of samples have different edge widths.

enlarged from 20 to 40 μ m for the fixed total width of 150 μ m. In conclusion, large anisotropy of the edge part of micropatterned films causes the increase of anisotropy dispersion, however, it is possible to give a solution by the edge pattern. This will enable us to utilize magnetic films for more downsized signal lines.

ACKNOWLEDGMENTS

The authors would like to thank Professor Osamu Kitakami (IMRAM Tohoku University) for VSM measurements and Professor Ken-Ichi Arai, Evaluation and Analysis Center (RIEC Tohoku University) and Venture Business Laboratory (Tohoku University) for fabrication of micropatterns. We also acknowledge the SCOPE program by the Ministry of Public Management Home Affairs, Posts and Telecommunications of Japan and the Collaboration Program between NEC TOKIN Co. and Tohoku University.

¹B. K. Kuanr, I. R. Harward, R. T. Deiotte, R. E. Camley, and Z. Celinski, J. Appl. Phys. **97**, 10Q103 (2005).

²S. Ikeda, Ki Hyeon Kim, and Masahiro Yamaguchi, J. Appl. Phys. 97, 10F912 (2005).

³S. Ikeda, K. H. Kim, M. Yamaguchi, K. I. Arai, H. Nagura, S. Ohnuma, and Y. Shimada, J. Magn. Soc. Jpn. 27, 594 (2003).

⁴J. A. Osborn, Phys. Rev. **67**, 351 (1945).

⁵M. Yamaguchi, Y. Miyazawa, K. Kaminishi, and K.-I. Arai, Trans. Magn. Soc. Jpn. **3**, 137 (2003).